

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicant	:	Sato et al.
Appl. No.	:	10/540,056
Filed	:	June 22, 2005
For	:	POSITIVE RESIST COMPOSITION AND METHOD OF FORMING RESIST PATTERN
Examiner	:	Chu, John S.Y.
Group Art Unit	:	1795

**RESPONSE TO OFFICE ACTION**

**Mail Stop Amendment**  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

In response to the Office Action mailed **August 8, 2008**, please consider the following amendments and remarks.

**Amendments to the claims** are reflected in the listing of claims which begins on page 2 of this paper.

**Remarks** begin on page 6 of this paper.